

This Page Is Inserted by IFW Operations
and is not a part of the Official Record

BEST AVAILABLE IMAGES

Defective images within this document are accurate representations of the original documents submitted by the applicant.

Defects in the images may include (but are not limited to):

- BLACK BORDERS
- TEXT CUT OFF AT TOP, BOTTOM OR SIDES
- FADED TEXT
- ILLEGIBLE TEXT
- SKEWED/SLANTED IMAGES
- COLORED PHOTOS
- BLACK OR VERY BLACK AND WHITE DARK PHOTOS
- GRAY SCALE DOCUMENTS

IMAGES ARE BEST AVAILABLE COPY.

**As rescanning documents *will not* correct images,
please do not report the images to the
Image Problem Mailbox.**

(19)



Europäisches Patentamt
European Patent Office
Office européen des brevets



(11)

EP 0 741 335 B1

(12)

EUROPEAN PATENT SPECIFICATION

(45) Date of publication and mention
of the grant of the patent:
18.10.2000 Bulletin 2000/42

(51) Int Cl. 7: G03F 7/20, G03F 7/24

(21) Application number: 96105784.1

(22) Date of filing: 12.04.1996

(54) Laser apparatus and process of use

Lasergerät und sein Gebrauch

Appareil laser et procédé pour son utilisation

(84) Designated Contracting States:
DE FR GB

- Van Zoeren, Carol M.
Wilmington, Delaware 19803 (US)

(30) Priority: 01.05.1995 US 432411

(74) Representative: Kuhnen & Wacker
Patentanwaltsgeellschaft mbH,
Alois-Steinecker-Strasse 22
85354 Freising (DE)

(43) Date of publication of application:
06.11.1996 Bulletin 1996/45

(56) References cited:
WO-A-92/02859 DE-A- 4 313 111
US-A- 5 262 275

(72) Inventors:

Remarks:

- Fan, Roxy Ni
East Brunswick, New Jersey 08816 (US)

The file contains technical information submitted
after the application was filed and not included in this
specification

EP 0 741 335 B1

Note: Within nine months from the publication of the mention of the grant of the European patent, any person may give notice to the European Patent Office of opposition to the European patent granted. Notice of opposition shall be filed in a written reasoned statement. It shall not be deemed to have been filed until the opposition fee has been paid. (Art. 99(1) European Patent Convention).

Description**BACKGROUND OF THE INVENTION****1. Field of the Invention.**

[0001] This invention relates to an apparatus and process for imagewise exposing an infrared sensitive layer and, more specifically, for imagewise ablating an infrared radiation sensitive layer of a flexographic printing element for use in making a flexographic printing plate.

2. Description of Related Art.

[0002] Flexographic printing plates are well known for use in letterpress printing, particularly on surfaces which are soft and easily deformable, such as packaging materials, e.g., cardboard and plastic films. Flexographic printing plates can be prepared from photopolymerizable compositions, such as those described in U.S. patents 4,323,637 and 4,427,749. The photopolymerizable compositions generally comprise an elastomeric binder, at least one monomer and a photoinitiator. Photosensitive elements generally have a photopolymerizable layer interposed between a support and a coversheet or multilayer cover element. Upon imagewise exposure to actinic radiation, polymerization, and hence, insolubilization of the photopolymerizable layer occurs in the exposed areas. Treatment with a suitable solution removes the unexposed areas of the photopolymerizable layer leaving a printing relief which can be used for flexographic printing.

[0003] Imagewise exposure of a photosensitive element requires the use of a phototool which is a mask having clear and opaque areas covering the photopolymerizable layer. The phototool prevents exposure and polymerization in the opaque areas. The phototool allows exposure to radiation in the clear areas so that these areas polymerize and remain on the support after the development step. The phototool is usually a photographic negative of the desired printing image. If corrections are needed in the final image a new negative must be made. This is a time-consuming process. In addition, the phototool may change slightly in dimension due to changes in temperature and humidity. Thus, the same phototool, when used at different times or in different environments, may give different results and could cause registration problems.

[0004] Thus, it would be desirable to eliminate the phototool by directly recording information on a photosensitive element, e.g., by means of a laser beam. The image to be developed could be translated into digital information and the digital information used to place the laser for imaging. The digital information could even be transmitted from a distant location. Corrections could be made easily and quickly by adjusting the digitized image. In addition, the digitized image could be either pos-

itive or negative, eliminating the need to have both positive-working and negative-working photosensitive materials, or positive and negative phototools. This saves storage space and, thus, reduces cost. Another advantage is that registration can be precisely controlled by machine during the imaging step. Digitized imaging without a phototool is particularly well-suited for making seamless, continuous printing forms.

[0005] In general, it has not been very practical to use lasers to image the elements which are used to prepare flexographic printing plates. The elements have low photosensitivity and require long exposure times even with high powered lasers. In addition, most of the photopolymerizable materials used in these elements have their greatest sensitivity in the ultraviolet range. While UV lasers are known, economical and reliable UV lasers with high power are generally not available. However, non-UV lasers are available which are relatively inexpensive, and which have a useful power output and which can be utilized to form a mask image on top of flexographic printing elements.

[0006] In view of these facts, a photosensitive printing element 10 has recently been developed for use in preparing flexographic print plates. Referring from bottom to top in Figure 1, the photosensitive printing element comprises, in order, a support or cushion layer 12, at least one photopolymerizable layer 14 which is substantially insensitive to infrared radiation, one or more optional barrier layer 16, and at least an infrared radiation sensitive layer 18. A removable protective coversheet 22 with an optional release layer 20 cover and protect the outer infrared radiation sensitive layer 18. See, for instance, U.S. patents 5,262,275 and 5,719,009, EP-A-0 792 478, EP-A-0 741 330 and EP-A-0 741 329.

[0007] The process of using these photosensitive printing elements involves (1) removing any protective coversheet 22 and the release layer 20, if present; (2) imagewise ablating the infrared-sensitive layer 18 to form a mask; (3) overall exposing the photosensitive element 10 to non-infrared actinic radiation through the mask; and (4) treating the product of step (3) with at least one developer solution to remove (i) the infrared-sensitive material which was not removed during step (2), (ii) at least the areas of any barrier layer 16, if present, which were not exposed to non-infrared actinic radiation, and (iii) the areas of the photopolymerizable layer 14 which were not exposed to non-infrared actinic radiation. The treating step (4) produces a flexographic printing plate with a relief surface or image which is inked and used for flexographic printing of typically multiple copies of the inked portions of the relief surface or image.

[0008] Conventional laser engraving systems are available for directly engraving relief images in materials for directly producing relief printing surfaces. Typical laser engravers use CO₂ lasers which emit a highly multimode beam having a wavelength of 10.6 μm which are very powerful lasers that would burn through or vaporize

most polymers including polymers in conventional flexographic printing elements and the entire elements disclosed in U.S. patents 5,262,275, and 5,719,009, EP-A-0 792-478, EP-A-0 741 330 and EP-A-0 741 329. Such engravers typically have a minimum resolution or beam diameter of 40 µm which is much too large for creating a high resolution flexographic printing mask. The maximum modulation rate of a CO₂ laser is 20 kHz which causes the maximum engraving speed to be too slow for a commercially viable system for forming high resolution mask layers on flexographic printing elements.

[0009] The Grapholas® system made and sold by Baasel-Scheel Lasergraphics, Gmb H, of Itzehoe, Germany, is for directly engraving relief images in a layer for directly producing relief printing surfaces. The Grapholas® system comprises:

a support assembly including:

a support,
a drum rotatably mounted on the support, the drum having an outer cylindrical surface, the layer adapted to be mounted on the cylindrical surface, and
a drum motor assembly mounted on the support, the drum motor assembly for rotating the drum with a maximum speed of 200 rpm;

a CO₂ laser assembly for producing an image modulated beam;

an optical assembly including:

a lens for focusing the directed beam having a minimum resolution of 40 µm at the layer on the cylindrical surface, and
a focusing motor assembly for moving the lens with respect to the layer on the cylindrical surface to focus the modulated beam such that the focused modulated beam is adapted to engrave the layer;

a modulated beam delivery carriage assembly including:

a carriage for supporting the optical assembly, a linear track along which the carriage is adapted to move, the track parallel to the longitudinal axis, and
a translator motor assembly for transporting the carriage along the track to scan the image modulated beam along the layer on the cylindrical surface at a carriage advance rate of about an engraving width of the modulated beam on the layer on the cylindrical surface;

a computer assembly for (i) receiving, generating and/or storing the image data representing an image to be engraved in the layer, and (ii) selecting

exposure parameters from a set consisting of the cylindrical surface speed, the support advance rate, image placement coordinates on the layer, focusing position, and amplitude modulation level; and an electronic control assembly for receiving the image data and the exposure parameters from the computer assembly and processing the image data and the exposure parameters to control the support assembly, the laser assembly, the optical assembly, and the linear transport mechanism to engrave the image in a spiral fashion in the layer.

[0010] Another engraving system previously made and sold by Baasel Lasertechnik, Gmb H called the Grapholas® Compact system was also for directly engraving relief images in a layer for directly producing relief printing surfaces. The Grapholas® Compact system comprised:

a support assembly including:

a support,
a drum rotatably mounted on the support, the drum having an outer cylindrical surface, the layer adapted to be mounted on the cylindrical surface, and
a drum motor assembly mounted on the support, the drum motor assembly for rotating the drum with a maximum speed of about 106 rpm;

a laser assembly for producing an image modulated beam, the laser assembly comprising:

a Nd:YAG laser for emitting an output infrared radiation beam,
a laser power supply for energizing the laser, and
a Q-switch for image modulating the output infrared radiation beam;

a stationary (i.e., fixed) optical assembly including:

a lens for focusing the directed beam at the layer on the cylindrical surface, and
a focusing motor assembly for moving the lens with respect to the layer on the cylindrical surface to focus the modulated beam such that the focused modulated beam is adapted to engrave the layer;

a linear transport mechanism for transporting the support, the drum and the drum motor assembly along a line to scan the image modulated beam along the layer on the cylindrical surface at a carriage advance rate of about an engraving width of the modulated beam on the layer on the cylindrical surface;

a computer assembly for (i) receiving, generating

and/or storing the image data representing an image to be engraved in the layer, and (ii) selecting exposure parameters from a set consisting of the cylindrical surface speed, the support advance rate, image placement coordinates on the layer, focusing position, and amplitude modulation level; and an electronic control assembly for receiving the image data and the exposure parameters from the computer assembly and processing the image data and the exposure parameters to control the support assembly, the laser assembly, the optical assembly, and the linear transport mechanism to engrave the image in a spiral fashion in the layer.

[0011] Since the structure and properties of the photosensitive printing elements disclosed in U.S. patents 5,262,275 and 5,719,009, EP-A-0 792 478, EP-A-0 741 330 and EP-A-0 741 329 are different than other materials that have been engraved by conventional engraving machines, such machines are not capable of forming a mask from the infrared radiation sensitive layer of the photosensitive printing elements disclosed in U.S. patents 5,262,275 and 5,719,009, EP-A-0 792 478, EP-A-0 741 330 and EP-A-0 741 329 in a commercially viable manner.

[0012] In fact, since these unique photosensitive printing elements were only recently developed, no apparatus is commercially available which is capable of ablating the infrared radiation sensitive layer of these photosensitive printing elements to form a suitable mask for use in preparing flexographic printing plates with desired productivity and image quality.

SUMMARY OF THE INVENTION

[0013] The invention provides an apparatus for imagewise exposing an infra-red sensitive layer, the apparatus comprising:

a support assembly including:

a rotatable cylindrical surface having a longitudinal axis, the layer adapted to be externally mounted on the cylindrical surface, and a motor assembly for rotating the cylindrical surface; a laser assembly for producing an image modulated beam; an optical assembly including:

a lens for focusing the directed beam at the layer on the cylindrical surface, and a focusing motor assembly for moving the lens with respect to the layer on the cylindrical surface to focus the modulated beam such that the focused modulated beam is adapted to engrave the layer;

a modulated beam delivery carriage assembly including:

a carriage for supporting the optical assembly, a linear track along which the carriage is adapted to move, the track parallel to the longitudinal axis, and

a translator motor assembly for transporting the carriage along the track to scan the image modulated beam along the layer on the cylindrical surface at a carriage advance rate of about an exposing width of the modulated beam on the layer on the cylindrical surface;

a computer assembly for (i) receiving, generating and/or storing image data representing an image to be exposed on the layer, and (ii) selecting exposure parameters from a set consisting of the cylindrical surface speed, the carriage advance rate, image placement coordinates on the layer, focusing position and amplitude modulation level; and an electronic control assembly for receiving the image data and the exposure parameters from the computer assembly and processing the image data and the exposure parameters to control the support assembly, the laser assembly, the optical assembly, and the modulated beam delivery carriage assembly to expose the image in a spiral fashion in the layer;

characterized in that said apparatus is capable of providing a focused modulated beam comprising infra-red radiation having a peak power density of 0.1 to 17 MW/cm² and is adapted to provide an energy density of 0.5 to 5 J/cm² on said layer sufficient to ablate the infra-red sensitive layer.

[0014] The invention is further directed to a process for making a flexographic printing plate, comprising:

(1) providing a photosensitive printing element comprising in the order listed:

- (a) a support layer,
- (b) at least a photopolymerizable layer comprising an elastomeric binder, at least a monomer and at least an initiator having sensitivity to non-infrared actinic radiation, said photopolymerizable layer being soluble, swellable or dispersible in a developer solution;
- (c) optionally at least a barrier layer which is substantially transparent to non-infrared actinic radiation; and
- (d) at least a layer of infra-red radiation sensitive material which is substantially opaque to non-infrared actinic radiation;

(2) imagewise ablating layer (d) with an infra-red laser radiation beam having a peak power density of 0.1 to 17 MW/cm² and adapted to provide an energy density of 0.5 to 5 J/cm² from a laser ablating apparatus to form a mask, the apparatus comprising

a support assembly, a laser assembly, an optical assembly, a modulated beam delivery carriage assembly, a computer assembly, and an electronic control assembly;

- (3) overall exposing the photosensitive element to non-infrared actinic radiation through the mask; and
- (4) treating the product of step (3) with at least one developer solution to remove (i) the infrared-sensitive layer which was not removed during step (2), (ii) at least areas of the barrier layer, if present, which were not exposed to non-infrared actinic radiation, and (iii) areas of the photopolymerizable layer (b) which were not exposed to non-infrared actinic radiation.

BRIEF DESCRIPTION OF THE DRAWINGS

[0015] The invention can be more fully understood from the following detailed description thereof in connection with accompanying drawings described as follows.

[0016] Figure 1 is a side or edge view of a recently invented photosensitive flexographic printing element, comprising, in order, from bottom to top, a support, a photopolymerizable layer which is substantially insensitive to infrared radiation, one or more optional barrier layer, an infrared radiation sensitive layer, an optional release layer, and a protective cover layer.

[0017] Figure 2 schematic illustration of an apparatus for ablating an image in the infrared radiation sensitive mask layer of the photopolymer flexographic printing element of Figure 1 in accordance with the present invention.

[0018] Figure 3 is a schematic illustration of an acousto-optic modulator assembly for modulating a laser output beam with image data.

[0019] Figure 4 is a cross sectional view of a first arrangement of the element on a first rotatable drum generally along line 4-4 in Figure 2 in the direction of the arrows.

[0020] Figure 5 is a cross sectional view of a second arrangement of the element on a sleeve which in turn is on a second rotatable drum generally along line 4-4 in Figure 2 in the direction of the arrows.

[0021] Figure 6 is a cross sectional view of a third arrangement of the element on the second rotatable drum generally along line 6-6 in Figure 5 in the direction of the arrows.

DESCRIPTION OF THE PREFERRED EMBODIMENT (S)

[0022] Throughout the following detailed description, similar reference characters refer to similar elements in all figures of the drawings.

[0023] Referring to Figure 2, there is an apparatus 200 for exposing an image in at least one infrared radiation sensitive layer 18 of a photosensitive material or

element 10 in accordance with the present invention. The layer 18 can be any infrared sensitive layer<where exposure to infrared radiation causes a physical or chemical change to material in the layer 18. Such changes include melting, hardening, softening, removing and color density changes.

[0024] As shown in Figure 1, the photosensitive element 10 preferably comprises a flexographic printing element or material 10 comprising, in order, a support or cushion layer 12, at least a photopolymerizable layer 14 which is substantially insensitive to infrared radiation, one or more optional barrier layer 16, and the at least one infrared radiation sensitive layer 18. Hereafter, when a single layer is mentioned, it is to be understood that the layer can be made of a plurality of layers of the same or varying thickness where the layers comprise the same or different composition. The layer 18 is ablatable by radiation having a peak power density of 0.1 to 17 MW/cm² and an energy density of 0.5 to 5 J/cm² without ablating or polymerizing the photopolymerizable layer 14.

Preferably, the layer 18 is ablatable by radiation having a peak power density of 0.5 to 9 MW/cm² and an energy density of 1 to 3 J/cm² without ablating or polymerizing the photopolymerizable layers 14. Most preferably, the layer 18 is ablatable by radiation having a peak power density of 2 to 7 MW/cm² and an energy density of 1.4 to 2.7 J/cm² without ablating or polymerizing the photopolymerizable layer 14.

[0025] The photosensitive element 10 can also include a temporary coversheet 22 on top of the infrared-sensitive layer 18. The purpose of the coversheet 22 is to protect the infrared-sensitive layer 18 during storage and handling. It is important that the coversheet 22 be removed prior to exposing the infrared-sensitive layer 18 to infrared laser radiation. An optional release layer 20 can be interposed between the coversheet 22 and the infrared-sensitive layer 18 to facilitate removal of the coversheet 22 from the infrared radiation sensitive layer 18. The optional release layer 20 is preferably removed with the coversheet 22. The photopolymerizable layer 14 comprise an elastomeric binder, at least a monomer and at least an initiator having sensitivity to non-infrared actinic radiation. The photopolymerizable layer 14 is soluble, swellable or dispersible in a developer solution. The barrier layer 16 is substantially transparent to non-infrared actinic radiation.

Preferably, the barrier layer 16 is soluble, swellable, dispersible, or liftable in the developer solution for the photopolymerizable layer 14. The infrared radiation sensitive layer 18 is substantially opaque to non-infrared actinic radiation. Suitable preferred photosensitive printing elements 10 are disclosed in U.S. patents 5,262,275 and 5,719,009, EP-A-0 792 478, EP-A-0 741 330 and EP-A-0 741 329.

[0026] The thickness of the infrared-sensitive layer 18 should be in a range to optimize both sensitivity and opacity. The layer 18 should be thin enough to provide

good sensitivity, i.e., the infrared-sensitive layer 18 should be removed rapidly upon exposure to infrared laser radiation. At the same time, the layer 18 should be thick enough so that areas of the layer 18 which remain on the photopolymerizable layer 14 after imagewise exposure effectively mask the photopolymerizable layer 14 from non-infrared actinic radiation. In general, the infrared-sensitive layer 18 will have a thickness from 2.0 nm (20 Angstroms) to 50 μm . It is preferred that the thickness be from 4.0 nm (40 Angstroms) to 40 μm .

[0027] The apparatus 200 comprises an element support assembly 210, a laser assembly 212, an optical assembly 214, a modulated beam delivery carriage assembly 216, a computer assembly 218, and an electronic control assembly 220.

[0028] The element support assembly 210 includes a rotatable cylindrical surface 222 and an element rotator motor assembly 224. The element support assembly 210 further comprises a stationary support frame 226 and a rotatable element support mechanism 228 supporting the cylindrical surface 222 which is rotatably supported at end portions by the support frame 226. The mechanism 228 can be a drum or shaft where an outer surface of the drum or shaft is the cylindrical surface 222. Alternatively, the mechanism 228 can be a mandrel or cylindrical axle 228 for inserting through a support sleeve 126 which comprises the cylindrical surface 222. The support sleeve 126 can be any material including a polymer, such as polyester, or a metal, such as nickel or a nickel alloy. See Figure 5. When the cylindrical surface 222 is an outer surface of the support sleeve 126, one end of the support frame 226 can be moved with respect to the drum 228 so the support sleeve 226 can be slid onto the drum 228. In another embodiment, the mechanism 228 is a set of support end caps or hubs for inserting in and holding ends of the support sleeve 126 in which case the support sleeve 126 again comprises the cylindrical surface 222. The cylindrical surface 222 has a longitudinal axis which is coincident with a longitudinal axis of the mechanism 228 (and the sleeve 126 when mounted on the mechanism 228). In each case, the cylindrical surface 222 has a preferred circumference of 24 inches to 50 inches. In a first arrangement illustrated in Figures 4 and 5, the photopolymer printing material 10 is adapted to be mounted on the cylindrical surface 222 with the infrared radiation sensitive layer 18 facing radially away from the cylindrical surface 222. In a second arrangement illustrated in Figure 6, the photopolymer printing material 10 is adapted to be mounted on the cylindrical surface 222 with the infrared radiation sensitive layer 18 facing radially towards the cylindrical surface 222. The element rotator motor assembly 224 is for rotating the cylindrical surface 222 and thereby the element 10 mounted on the cylindrical surface 222. Referring to Figure 4, the temporary coversheet 22 and the release layer 20, if present, should be removed prior to mounting the element 10 on the mechanism 228 and thus prior to imagewise ablation of the infrared sensitive

layer 18. Referring back to Figure 2, the element rotator motor assembly 224 is capable of rotating the cylindrical surface 222 at a speed of about 500 to about 2500 revolutions per minute. Preferably, the element rotator motor assembly 224 rotates the cylindrical surface 222 at a speed of 700 to 2500 revolutions per minute, and most preferably at a speed of 1000 to 2000 revolutions per minute. Surface velocity of a point on the cylindrical surface 222 is 5 to 53 m/s.

[0029] The laser assembly 212 is for producing an image modulated beam 230. The laser assembly 212 comprises a laser 232, a laser power supply 234 and an acousto-optic modulator assembly 236. The laser 232 is for emitting an output infrared radiation beam 238 having a M^2 beam quality value or factor of 4 to 8 and a maximum power of 50 to 70 W. Preferably, the beam 238 has a M^2 beam quality value of 5 to 7 and, most preferably, a M^2 beam quality value of 5.5 to 6.5. For articles defining, and describing methods of measuring, the M^2 beam quality value of lasers, see A. E. Siegman, New Developments in Laser Resonators, SPIE Vol. 1224, Optical Resonators (1990); T. F. Johnson, Jr., M^2 Concept Characterizes Beam Quality, Laser Focus World, May 1990; and M. W. Sasnett, Characterization of Laser Beam Propagation, Coherent, September 1990. The laser output beam 238 has a $1/e^2$ irradiance diameter at its waist diameter of 2 millimeters to 3 millimeters.

[0030] Various infrared lasers can be used. Diode lasers emitting in the region of 750 to 880 nm offer substantial advantages in terms of their small size, low cost, stability, reliability, ruggedness and ease of modulation. Diode lasers emitting in the range of 780 to 850 nm are preferred. Such lasers are commercially available from, for example, Spectra Diode Laboratories (San Jose, CA). Most preferably, the laser 232 is a Nd:YAG laser which is adapted to emit at about 1064 nm. The laser power supply 234 is for energizing the laser 232 over line 233. The acousto-optic modulator assembly 236 is

for modulating the laser output beam 238 with image data and for producing the image modulated beam 230 which can be a first order beam having a maximum power of about 22 Watts to about 32 Watts. The image modulated beam 230 has a wavelength of about 780 nanometers to about 2000 nanometers. Preferably, the acousto-optic modulator assembly 236 is adapted to provide an image modulation rate in a range of 0.5 to 1.0 megabits/second.

[0031] Referring to Figure 3, the acousto-optic modulator assembly 236 comprises an acousto-optic modulator 240 and a beam dump 242. The acousto-optic modulator 240 is for diffracting a first order beam portion (which in Figure 3 is beam 230) of the laser output beam 238 and passing a zero order beam portion 244 of the laser output beam 238. The beam dump 242 is for blocking either the first order beam portion 230 of the laser output beam 238 or the zero order beam portion 244 of the laser output beam 238. The acousto-optic modulator

assembly 236 further comprises a radio frequency (RF) driver 246 which receives image data over a line 237 from the electronic control assembly 220. The RF driver 246 sends an RF drive signal over a line 250 to a transducer 252 of the acousto-optic modulator 240. A suitable acousto-optic modulator 240 is commercially available under model number AOM-40R from IntraAction Corporation of Bellwood, Illinois. A suitable RF driver 246 is commercially available under model ME (Signal Processor) also from IntraAction Corporation.

[0032] Referring back to Figure 2, the optical assembly 216 includes a lens 262 mounted on a lens support 264, a linear track 266, and a focusing motor assembly 268. Preferably, a reflector 260 is included in the optical assembly 216. The reflector 260 is for directing the image modulated beam 230 onto the infrared sensitive layer 18 of the material 10 on the cylindrical surface 222. The lens 262 is for focusing the directed beam at the infrared sensitive layer 18 of the material 10 on the cylindrical surface 222. The modulated beam focused by the lens 262 comprises infrared radiation having a peak power density of 0.1 to 17 MW/cm² and provides an energy density of 0.5 to 5 J/cm² on the layer 18. Preferably, the focused modulated beam has a peak power density of 0.5 to 9 MW/cm² and provides an energy density of 1 to 3 J/cm². Most preferably, the focused modulated beam has a peak power density of 2 to 7 MW/cm² and provides an energy density of 1.4 to 2.7 J/cm². The lens 262 is adapted to focus the directed beam to have a 1/e² irradiance diameter of 15 μm to 30 μm at the infrared sensitive layer 18 of the material 10 on the cylindrical surface 222. Preferably, the lens 262 focuses the beam to a 1/e² irradiance diameter of 20 μm to 25 μm at the infrared sensitive layer 18. The focusing motor assembly 268 is for moving the lens 262 with respect to the infrared sensitive layer 18 of the material 10 on the cylindrical surface 222 to focus the modulated beam such that the focused modulated beam is adapted to ablate the infrared sensitive layer 18. The linear track 266 can be a worm gear connected at one end to a drive shaft of the focusing motor assembly 268. The worm gear 266 can be adapted to engage a mating socket in the lens support 264 such that when the focusing motor assembly 268 rotates the worm gear 266, the lens support 264 and the lens 262 move linearly along the track 266. The optical assembly 216 can be mounted on a carriage 280 which can block rotational movement of the lens support 264 during its linear movement along the track 266. The laser assembly 212 can be mounted on the carriage 280 in which case the reflector 260 is unnecessary. One or more additional reflector 261 can be used to direct the beam 230 onto the reflector 260 or lens 262 in order to position the laser 232 in a compact position in the apparatus 200. If needed, a beam expander 263 can be used to increase the diameter of the modulated beam 230.

[0033] Assuming a Gaussian laser beam, the peak power density or irradiance occurs at the center of the

beam and is given by Formula I below.

$$\text{Peak Power Density} = \frac{8 P_T}{\pi d_o^2} \quad (\text{I})$$

where

P_T = Total Power (Watt) in beam; and
 $d_o = 1/e^2$ irradiance diameter of beam.

[0034] For instance, where $P_T = 10 \text{ W}$ and $d_o = 25 \mu\text{m}$:

$$\text{PeakPowerDensity} = \frac{[8][10 \text{ W}]}{[\pi][0.0025 \text{ cm}]^2} = 4.1 \text{ MW/cm}^2$$

Further, the Energy Density or Exposure delivered to an area on an outer circumferential surface of a drum is given by Formula II below.

$$\text{Energy Density} = - \frac{P_T}{[\text{rps}][D_C][W_A]} \quad (\text{II})$$

where

P_T = Total Power (W or J/s) in beam;
 rps = drum revolutions each second;
 D_C = drum circumference (cm); and
 W_A = advance width (cm) of beam along longitudinal axis of drum each revolution of the drum.

[0035] For instance, when $P_T = 10 \text{ W}$, drum circumference = 75 cm, advance width = 25 μm:

$$\text{EnergyDensity} = \frac{[10 \text{ W}]}{[1500 \text{ revs}/60\text{s}][75 \text{ cm}][0.0025 \text{ cm}]} = 2.1 \text{ J/cm}^2$$

[0036] When the modulated beam 230 is focused on the infrared sensitive layer 18, material in the infrared-sensitive layer 18 is removed, i.e., ablated or engraved, in the areas exposed to the infrared laser radiation. For the purposes herein, the term "ablated" means removed by cutting, erosion, melting, evaporation, burning, decomposition or vaporization. In the printing field, the term "engrave" is defined as to impress deeply to cut figures, letters, or images into a substrate to form a relief surface to be inked in the printing process. In a preferred use of the apparatus 200 to make flexographic printing plates, the term "engrave" is defined to be synonymous with the word "ablate" with the understanding that the depth of material removed is much less than prior engraving processes, the material being removed is different than in prior engraving processes, and the resulting

engraved layer is used as a photomask for forming a printing relief surface from another layer removed from the engraved layer, rather than used as the printing relief surface itself.

[0037] The modulated beam delivery carriage assembly 216 includes the carriage 280, a linear track 282 and a translator motor assembly 284. The carriage 280 as stated before supports the optical assembly 214. The carriage 280 is adapted to move linearly along the track 262, for instance, in a manner similar to the way the lens support 264 moves along the track 266. The track 282 is parallel to the longitudinal axis of the cylindrical surface 222. The translator motor assembly 284 is for transporting the carriage 280 along the track 282 to scan the image modulated beam along the infrared sensitive layer 18 of the material 10 on the cylindrical surface 222 at a carriage advance rate of about an ablating width of the modulated beam on the infrared sensitive layer 18 of the material 10 on the cylindrical surface 222.

[0038] The computer assembly 218 is for (i) receiving, generating and/or storing the image data representing an image to be ablated in the infrared radiation sensitive layer 18, and (ii) selecting exposure parameters from a set consisting of the speed of the cylindrical surface 222, the advance rate of the carriage 280, image placement coordinates on the infrared radiation sensitive layer 18, focus position of the lens 262, and amplitude modulation level provided by the acousto-optic modulator assembly 236.

[0039] The electronic control assembly 220 is for receiving the image data and the exposure parameters from the computer assembly 218 over line 219 and processing the image data and the exposure parameters to control the support assembly 210 over line 211 to the motor assembly 224, the laser assembly 212 over lines 213 and 237, the optical assembly 214 over line 215 to the motor assembly 268, and over line 217 to the motor assembly 284 of the modulated beam delivery carriage assembly 216 to ablate the image in a spiral fashion in the infrared radiation sensitive layer 18 without ablating or polymerizing the photopolymerizable layer 14 beneath the infrared sensitive layer 18. See Figure 4. An encoder 270 which is connected to the motor assembly 224 provides feedback on the operation of the motor assembly 224 to the electronic control assembly 220 over line 272. The electronic control assembly 220 is also adapted to control the acousto-optic modulator assembly 236 over line 237. The electronic control assembly 220 is further adapted to be used to select at least one exposure parameter from a set consisting of the cylindrical surface speed, the carriage advance rate, the image placement coordinates on the infrared radiation sensitive layer 18, the lens focus position and the amplitude modulation level.

[0040] The ablating apparatus 200 preferably further comprises a debris extraction system 286 for removing ablated material. Then the electronic control assembly 220 would be adapted to control the debris extraction

system 286 over line 287. The debris extraction system 286 can be mounted on, and thereby move with, the carriage 280. The debris extraction system 286 can be the same as or similar to the debris extraction system in any of the commercially available Grapholas® systems.

[0041] The ablating apparatus 200 preferably further comprises means for mounting the material 10 on the cylindrical surface 222. The mounting means can be any means such as a sheet 127 of tape with adhesive layers on both sides as shown in Figure 4. In this embodiment, the tape is preferably placed on the drum 228 and then the support layer 12 is mounted on the tape 127. Alternatively, the mounting means can comprise clamps or a vacuum retaining system 290 as shown in Figures 2 and 5. The vacuum retaining system 290 can comprise a vacuum and/or pressure source 292 connected by a conduit 294 to an interior cavity 295 within the drum 228 having closed ends. The conduit 294 can be connected through one of the ends of the drum 228 through a rotatable air tight connection. Passages 296 extend radially through the drum 228 from the interior cavity 295 to the cylindrical surface 222. When the source 292 creates a vacuum in the cavity 295 and the element 10 is mounted on the drum 228, the vacuum force secures the element 10 to, and prevents the element 10 from moving with respect to, the drum 228. In this embodiment, the layer 12 can be mounted in direct contact with the drum 228. Alternatively, as shown in Figure 5, the element 10 can be secured by a sheet 128 of double sided cushion tape to the sleeve 126 which, in turn, is mounted on the drum 228. The cushion tape 128 can be the same as tape 127 or provide more cushion for the element 10. When the sleeve 126 is used and the source 292 supplies air to the cavity 295, air is forced out of the passages 296 which facilitates sliding the element 10 mounted on the sleeve 126 on the drum 228.

[0042] Figure 6 illustrates the arrangement where the photopolymer printing material 10 is adapted to be mounted on the cylindrical surface 222 with the infrared radiation sensitive layer 18 facing radially towards the cylindrical surface 222. In this arrangement, a material capture sheet 130 as described in EP-A-0 741 329 is placed on the cylindrical surface 222 of the vacuum drum 228. Then the element 10 is placed on the material capture sheet 130 and on areas of the cylindrical surface 222 surrounding the material capture sheet. A vacuum force from source 292 secures the material capture sheet 130 and the element 10 on the drum 228. Of course, any means can be used for mounting the material capture sheet 130 and the element 10 on the drum 228.

[0043] It is contemplated that the imagewise exposure to infrared radiation and an overall exposure to actinic radiation including non-infrared radiation such as visible and/or ultraviolet radiation, can be carried out in the apparatus 200.

[0044] Unless otherwise indicated, the term "flexographic printing plate or element" encompasses plates

or elements in any form suitable for flexographic printing, including, but not limited to, flat sheets and seamless continuous cylindrical forms. The photopolymerizable flatsheet elements 10 can be reprocessed by wrapping the element 10 around a cylindrical form, such as the printing sleeve 126 or a printing cylinder itself, and fusing the edges together to form a seamless, continuous element.

[0045] Continuous printing elements have applications in the flexographic printing of continuous designs such as in wallpaper, decoration and gift wrapping paper. Furthermore, such continuous printing elements are well-suited for mounting on the laser apparatus 200. The sleeve or cylinder on which the printing element 10 is wrapped when the edges are fused, can be mounted directly into the laser apparatus 200 where it functions as the cylindrical surface 222.

Process for Producing a Flexographic Printing Plate

[0046] The process of the invention involves (1) providing the photosensitive printing element 10 as described above; (2) imagewise ablating the infrared sensitive layer 18 of the element 10 with an infrared laser radiation beam having a peak power density as defined above and an energy density as defined above from the apparatus 200 to form a mask; (3) overall exposing the photosensitive element to non-infrared actinic radiation through the mask; and (4) treating the product of step (3) with at least one developer solution to remove (i) the infrared-sensitive layer 18 which was not removed during step (2), (ii) at least areas of the barrier layer(s) 16, if present, which were not exposed to non-infrared actinic radiation, and (iii) areas of the photopolymerizable layer 14 which were not exposed to non-infrared actinic radiation.

[0047] Prior to the imagewise ablating step, the coversheet 22 and the optional release layer 20, if present, is/are removed from the element 10. After the removing step and prior to the ablating step, the element 10 is mounted on the rotatable cylindrical surface 222 of the support assembly 228.

[0048] The imagewise ablating step is performed by directing the focused modulated beam on the photosensitive element 10. In the infrared imagewise ablating step, material in the infrared-sensitive layer 18 is removed, i.e., ablated or engraved, in the areas exposed to the infrared laser radiation. The areas exposed to laser radiation in the infrared-sensitive layer 18 correspond to those areas in the photopolymerizable layer 14 which will be polymerized to form the final printing plate. After laser ablation, a pattern of actinic radiation-opaque material remains on the barrier layer 16 or directly on the photopolymerizable layer 14 when the barrier layer 16 is not present. The areas in which the infrared-sensitive layer 18 remains correspond to the areas of the photopolymerizable layer 14 which will be washed out in the formation of the final printing plate.

[0049] The ablating step is performed by rotating the cylindrical surface 222 at a speed as described above while simultaneously moving the optical assembly 214 generally parallel to a longitudinal axis of the cylindrical surface 222 to ablate an image in a spiral fashion in the infrared sensitive layer 18 at an advance rate of about an ablating width on the layer 18 per revolution of the cylindrical surface 222. This is done with the infrared laser radiation beam focused to have a diameter as described above.

[0050] The next step in the process of the invention is to overall expose the photosensitive element 10 to actinic radiation through the mask. The type of radiation used is dependent on the type of photoinitiator in the photopolymerizable layer 18. The radiation-opaque material in the infrared sensitive layer 18 which remains on top of the barrier layer 16 on the photopolymerizable layer 14 prevents the material beneath from being exposed to the radiation and hence those areas covered by the radiation-opaque material do not polymerize. The areas not covered by the radiation-opaque material are exposed to actinic radiation and polymerize. Any conventional sources of actinic radiation can be used for this exposure step. Examples of suitable visible or UV sources include carbon arcs, mercury-vapor arcs, fluorescent lamps, electron flash units, electron beam units and photographic flood lamps. The most suitable sources of UV radiation are the mercury-vapor lamps, particularly the sun lamps. A standard radiation source is the Sylvania 350 Blacklight fluorescent lamp (FR 48T12/350 VL/VHO/120, 115 w) which has a central wavelength of emission around 354 nm.

[0051] The actinic radiation exposure time can vary from a few seconds to minutes, depending upon the intensity and spectral energy distribution of the radiation, its distance from the photosensitive element 10, and the nature and amount of the photopolymerizable composition in layer 14. Typically a mercury vapor arc or a sun-lamp is used at a distance of 3.8 to 153 cm (1.5 to 60 inches) from the photosensitive element 10. Exposure temperatures are preferably ambient or slightly higher, i.e., 20° to 35°C.

[0052] The process of the invention usually includes a back exposure or backflash step. This is a blanket exposure to actinic radiation through the support or cushion layer 12. It is used to create a shallow layer of polymerized material, or a floor, on the support side of the photopolymerizable layer 14 and to sensitize the photopolymerizable layer 14. The floor provides improved adhesion between the photopolymerizable layer 14 and the support or cushion layer 12, helps highlight dot resolution and also establishes the depth of the plate relief. The backflash exposure can take place before, after or during the other imaging steps (i.e., the ablating step and the exposing step). It is preferred that it take place just prior to the imagewise ablating with infrared laser radiation on the infrared-sensitive layer 18 side of the element 10.

[0053] Any of the conventional radiation sources discussed above can be used for the backflash exposure step. Exposure time generally range from a few seconds up to about a minute.

[0054] Following overall exposure to UV radiation through the mask formed by the actinic radiation-opaque material, the image is treated or developed by washing with a suitable developer. The developer removes (i) the infrared-sensitive material which was not removed during the ablation step, (ii) the barrier layer 16, if present, in at least the areas which were not exposed to non-infrared actinic radiation, and (iii) the photopolymerizable layer 14 in the areas which were not exposed to non-infrared actinic radiation. Development is usually carried out at about room temperature. The developers can be organic solutions, water, aqueous or semi-aqueous solutions. The choice of the developer will depend on the chemical nature of the photopolymerizable material to be removed. Suitable organic solution developers include aromatic or aliphatic hydrocarbon and aliphatic or aromatic halohydrocarbon solutions, or mixtures of such solutions with suitable alcohols. Other organic solution developers have been disclosed in DE-A-38 28 551 and U.S. Patent 5,354,645. Suitable semi-aqueous developers usually contain water and a water miscible organic solution and an alkaline material. Suitable aqueous developers usually contain water and an alkaline material. Other suitable aqueous developer combinations are described in U.S. Patent 3,796,602.

[0055] Development time can vary, but it is preferably in the range of about 2 to 25 minutes. Developer can be applied in any convenient manner, including, immersion, spraying and brush or roller application. Brushing aids can be used to remove the unpolymerized portions of the composition. However, washout is frequently carried out in an automatic processing unit which uses developer and mechanical brushing action to removed the unexposed portions of the plate, leaving a relief constituting the exposed image and the floor.

[0056] A pre-development step may be necessary if the infrared-sensitive layer 18 is not removable by the developer solution. An additional developer, which does not effect the polymerized photosensitive material can be applied to remove the infrared-sensitive layer first. This is particularly true when metallic materials are used. In such cases, etching solutions are used, such as 2% aqueous KOH solution.

[0057] The process of this invention may be simplified by removing in the treating step with brushing the infrared sensitive layer 18, and/or the barrier layer 16, if present, at the same time as the removal of the unexposed portions of the photopolymer layer 14. The pre-treating step may not be necessary in the situation in which the photosensitive element 10 includes a infrared sensitive layer 18 and/or barrier layer 16 which is not substantially soluble, swellable, dispersible, or liftable in the developer solution for the photopolymer layer 14.

The infrared sensitive layer 18 and the barrier layer 16 are generally much thinner than the photopolymer layer 14 such that with the aid of brushing or brushing with pressure, the infrared and barrier layers 18,16 can be easily removed from the photopolymer layer 14. Since automatic processing units which use mechanical brushing action are in use commercially for development of photopolymeric plates, the need for brushing action during washout is easily accomplished.

[0058] Following solution development, the relief printing plates are generally blotted or wiped dry, and then dried in a forced air or infrared oven. Drying times and temperatures may vary, however, typically the plate is dried for 60 to 120 minutes at 60°C. High temperatures are not recommended because the support 12 can shrink and this can cause registration problems.

[0059] Most flexographic printing plates are uniformly post-exposed to ensure that the photopolymerization process is complete and that the plate will remain stable during printing and storage. This post-exposure step utilizes the same radiation source as the main exposure to actinic radiation including non-infrared radiation.

[0060] Detackification is an optional post-development treatment which can be applied if the surface is still tacky, such tackiness not generally being removed in post-exposure. Tackiness can be eliminated by methods well known in the art, such as treatment with bromine or chlorine solutions. Such treatments have been disclosed in, for example, Grüetzmacher U.S. Patent 4,400,459, Fickes et al., U.S. Patent 4,400,460 and German Patent 28 23 300. Detackification can also be accomplished by exposure to radiation sources having a wavelength not longer than 300 nm, as disclosed in EP-A-0 017 927 and U.S. Patent 4,806,506.

[0061] Imagewise ablation, overall exposure, development and any additional steps can be performed while the plate is mounted in the round. Other advantages which can be obtained using the instant process include increased process speed, better registration and reduced or in some cases no extra mounting time.

Claims

45. 1. An apparatus for imagewise exposing an infra-red sensitive layer, the apparatus comprising:
a support assembly including:
a rotatable cylindrical surface having a longitudinal axis, the layer adapted to be externally mounted on the cylindrical surface, and
a motor assembly for rotating the cylindrical surface;
a laser assembly for producing an image modulated beam;

an optical assembly including:

a lens for focusing the directed beam at the layer on the cylindrical surface, and
a focusing motor assembly for moving the lens with respect to the layer on the cylindrical surface to focus the modulated beam such that the focused modulated beam is adapted to engrave the layer;

5

10

a modulated beam delivery carriage assembly including:

a carriage for supporting the optical assembly,
a linear track along which the carriage is adapted to move, the track parallel to the longitudinal axis, and
a translator motor assembly for transporting the carriage along the track to scan the image modulated beam along the layer on the cylindrical surface at a carriage advance rate of about an exposing width of the modulated beam on the layer on the cylindrical surface;

15

20

25

a computer assembly for (i) receiving, generating and/or storing image data representing an image to be exposed on the layer, and (ii) selecting exposure parameters from a set consisting of the cylindrical surface speed, the carriage advance rate, image placement coordinates on the layer, focusing position and amplitude modulation level; and
an electronic control assembly for receiving the image data and the exposure parameters from the computer assembly and processing the image data and the exposure parameters to control the support assembly, the laser assembly, the optical assembly, and the modulated beam delivery carriage assembly to expose the image in a spiral fashion in the layer;

30

35

40

45

characterized in that said apparatus is capable of providing a focused modulated beam comprising infra-red radiation having a peak power density of 0.1 to 17 MW/cm² and is adapted to provide an energy density of 0.5 to 5 J/cm² on said layer sufficient to ablate the infra-red sensitive layer.

50

2. The apparatus of claim 1, wherein:

the laser assembly comprises:

a laser for emitting an output infra-red radiation beam having an M² beam quality value of 4 to 8 and a maximum power of 50-70 W;

55

a laser power supply for energizing the laser; and

an acousto-optic modulator assembly for modulating the laser output beam with image data and for producing an image modulated first order beam having a maximum power of 22 to 32 W; and

the electronic control assembly is adapted to control the acousto-optic modulator assembly.

3. The apparatus of claim 2, wherein the acousto-optic modulator assembly comprises:

an acousto-optic modulator for diffracting a first order beam portion of the laser output beam and passing a zero order beam portion of the laser output beam; and
a beam dump for blocking either the first order beam portion or the zero order beam portion.

4. The apparatus of claim 1, further comprising a debris extraction system for removing ablated material, the electronic control assembly further adapted to control the debris extraction system.

5. A process for making a flexographic printing plate, comprising:

(1) providing a photosensitive printing element comprising in the order listed:

(a) a support layer,
(b) at least a photopolymerizable layer comprising an elastomeric binder, at least a monomer and at least an initiator having sensitivity to non-infrared actinic radiation, said photopolymerizable layer being soluble, swellable or dispersable in a developer solution;
(c) optionally at least a barrier layer which is substantially transparent to non-infrared actinic radiation; and
(d) at least a layer of infra-red radiation sensitive material which is substantially opaque to non-infrared actinic radiation;

(2) imagewise ablating layer (d) with an infrared laser radiation beam having a peak power density of 0.1 to 17 MW/cm² and adapted to provide an energy density of 0.5 to 5 J/cm² from a laser ablating apparatus to form a mask, the apparatus comprising a support assembly, a laser assembly, an optical assembly, a modulated beam delivery carriage assembly, a computer assembly, and an electronic control assembly;

(3) overall exposing the photosensitive element

- to non-infrared actinic radiation through the mask; and
 (4) treating the product of step (3) with at least one developer solution to remove (i) the infrared-sensitive layer which was not removed during step (2), (ii) at least areas of the barrier layer, if present, which were not exposed to non-infrared actinic radiation, and (iii) areas of the photopolymerizable layer (b) which were not exposed to non-infrared actinic radiation.
6. The process of claim 5, further comprising:
 removing a coversheet from the element; and
 after the removing step and prior to the ablating step, mounting the element on a rotatable cylindrical surface of the support assembly.
7. The process of claim 5, further comprising:
 providing the infra-red laser radiation beam having a M^2 beam quality value of 4 to 8 and a maximum power of 50-70 W.
8. The process of claim 5, wherein the ablating step is performed by:
 rotating the cylindrical surface at a speed of 500 to 2500 revolutions per minute while simultaneously moving the optical assembly generally parallel to a longitudinal axis of the cylindrical surface to ablate an image in a spiral fashion in the layer (d) at an advance rate of about an ablating width on the layer per revolution of the cylindrical surface.
9. The process of claim 5, further comprising focusing the infra-red laser radiation beam to have a $1/e^2$ irradiance diameter of 15 μm to 30 μm at the layer (d).
- Patentansprüche**
1. Vorrichtung zum bildweisen Belichten einer infrarotempfindlichen Schicht, wobei die Vorrichtung umfaßt:
 eine Trägereinheit, die einschließt:
 eine drehbare zylindrische Oberfläche mit einer Längsachse, wobei die Schicht außen an der zylindrischen Oberfläche befestigt wird, und
 eine Motoreinheit zum Drehen der zylindrischen Oberfläche;
- eine Lasereinheit zum Erzeugen eines Bildmodulierten Strahls;
- eine optische Einheit, die einschließt:
- eine Linse zum Fokussieren des gerichteten Strahls auf der Schicht auf der zylindrischen Oberfläche, und
 eine fokussierende Motoreinheit zum Bewegen der Linse in bezug auf die Schicht auf der zylindrischen Oberfläche, um den modulierten Strahl so zu fokussieren, daß der modulierte Strahl die Schicht graviert;
- eine Transporteinheit für den modulierten Strahl, die einschließt:
 einen Schlitten zum Tragen der optischen Einheit,
 eine lineare Spur, entlang der der Schlitten bewegt wird, wobei die Spur zur Längsachse parallel ist, und eine Umsetzungsmotoreinheit zum Transportieren des Schlittens entlang der Spur, damit der Bildmodulierte Strahl die Schicht auf der zylindrischen Oberfläche abtasten kann, mit einer Vorschubgeschwindigkeit des Schlittens, die etwa einer Belichtungsbreite des modulierten Strahls auf der Schicht auf der zylindrischen Oberfläche entspricht;
- eine Rechnereinheit zum (i) Empfangen, Erzeugen und/oder Speichern von Bilddaten, die ein Bild darstellen, das auf die Schicht exposiert werden soll, und zum (ii) Auswählen von Exponierungsparametern aus einer Gruppe, die aus der Geschwindigkeit der zylindrischen Oberfläche, der Vorschubgeschwindigkeit des Schlittens, der Bildkoordinaten auf der Schicht, der Fokussierungsposition und dem Amplituden-Modulationsgrad besteht; und
- eine elektronische Steuerungseinheit zum Empfangen der Bilddaten und der Belichtungsparameter von der Rechnereinheit und zum Verarbeiten der Bilddaten und der Belichtungsparameter, um die Trägereinheit, die Lasereinheit, die optische Einheit und die Transporteinheit für den Bild-modulierten Strahl zu steuern, um spiralförmig ein Bild in der Schicht zu exponieren;
- dadurch gekennzeichnet, daß die Vorrichtung in der Lage ist, einen fokussierten modulierten Strahl bereitzustellen, der Infrarotstrahlung mit einer Spitzenleistungsdichte von 0,1 bis 17 MW/cm² umfaßt, und eine Energiedichte von 0,5 bis 5 J/cm² auf der Schicht bereitstellt, die ausreicht, um die infrarotempfindliche Schicht zu ablatieren.
2. Vorrichtung nach Anspruch 1, wobei:
 die Lasereinheit umfaßt:

- einen Laser zum Aussenden eines Infrarotstrahls mit einem M^2 -Wert des Strahls von 4 bis 8 und einer maximalen Leistung von 50 - 70 W; eine Läserenergiequelle zum Versorgen des Lasers mit Energie; und eine akustisch-optische Modulationseinheit zum Modulieren des ausgesendeten Laserstrahls mit Bilddaten und zum Erzeugen eines Bild-modulierten Strahls erster Ordnung mit einer maximalen Leistung von 22 bis 32 W; und
- die elektronische Steuerungseinheit die akustisch-optische Modulationseinheit steuert.
3. Vorrichtung nach Anspruch 2, wobei die akustisch-optische Modulationseinheit umfaßt:
- einen akustisch-optischen Modulator, um einen Strahlabschnitt erster Ordnung des ausgesendeten Laserstrahls zu beugen und einen Strahlabschnitt nullter Ordnung des ausgesendeten Laserstrahls durchzuleiten; und einen Strahlendump zum Blockieren von entweder dem Strahlabschnitt erster Ordnung oder dem Strahlabschnitt nullter Ordnung.
4. Vorrichtung nach Anspruch 1, weiterhin umfassend ein Abrieb-Absaugungssystem zum Entfernen des ablatierten Materials, wobei die elektronische Steuerungseinheit zusätzlich das Abrieb-Absaugungssystem steuert.
5. Verfahren zum Erzeugen einer Flexodruckplatte, umfassend:
- (1) Bereitstellen eines lichtempfindlichen Druckelements, das in der angegebenen Reihenfolge enthält:
- (a) eine Trägerschicht,
- (b) wenigstens eine photopolymerisierbare Schicht, die ein elastomeres Bindemittel, wenigstens ein Monomer und wenigstens einen Initiator, der gegenüber aktinischer Strahlung empfindlich ist, aufweist, wobei die photopolymerisierbare Schicht in einer Entwicklerlösung löslich, quellfähig oder dispergierbar ist;
- (c) optional wenigstens eine Sperrsicht, die im wesentlichen durchlässig für nicht-infrarote aktinische Strahlung ist; und
- (d) wenigstens eine Schicht aus für aktinische Infrarotstrahlung undurchlässigem Material;
- (2) bildweises Ablatieren der Schicht (d) mit einem Infrarot-Laserstrahl mit einer Spitzenleistungsdichte von 0,1 bis 17 MW/cm², der eine Energiedichte von 0,5 bis 5 J/cm² aus einer Laser-Ablationsvorrichtung bereitstellt, um eine Maske zu bilden, wobei die Vorrichtung eine Trägereinheit, eine Lasereinheit, eine optische Einheit, eine Transporteinheit für den modulierten Strahl, eine Rechnereinheit und eine elektronische Steuerungseinheit umfaßt;
- (3) Belichten des gesamten lichtempfindlichen Elements mit nicht-infraroter aktinischer Strahlung durch die Maske hindurch; und
- (4) Behandeln des Produkts von Schritt (3) mit wenigstens einer Entwicklerlösung, um (i) die lichtempfindliche Schicht, die während Schritt (2) nicht entfernt worden war, (ii) mindestens die Bereiche der Sperrsicht, die nicht mit nicht-infraroter aktinischer Strahlung belichtet worden waren, falls vorhanden, und (iii) die Bereiche der photopolymerisierbaren Schicht (b), die nicht mit nicht-infraroter aktinischer Strahlung belichtet worden waren, zu entfernen.
6. Verfahren nach Anspruch 5, weiterhin umfassend: Entfernen der Deckfolie von dem Element; und, nach dem Schritt des Entfernens und vor dem Ablationsschritt, Befestigen des Elements auf einer drehbaren zylindrischen Oberfläche auf der Trägereinheit.
7. Verfahren nach Anspruch 5, weiterhin umfassend: Bereitstellen des Infrarot-Laserstrahls mit einem M^2 -Wert des Strahls von 4 bis 8 und einer maximalen Leistung von 50 - 70 W.
8. Verfahren nach Anspruch 5, wobei der Ablationsstrahl durchgeführt wird, indem man:
- die zylindrische Oberfläche mit einer Geschwindigkeit von 500 bis 2500 Umdrehungen pro Minute dreht, während man gleichzeitig die optische Einheit im wesentlichen parallel zur Längsachse der zylindrischen Oberfläche bewegt, um durch spiralförmiges Ablatieren ein Bild in der Schicht (d) zu erzeugen bei einer Vorschubgeschwindigkeit, die etwa einer Ablationsbreite auf der Schicht pro Umdrehung der zylindrischen Oberfläche entspricht.
9. Verfahren nach Anspruch 5, weiterhin umfassend das Fokussieren des Infrarot-Laserstrahls, um eine Bestrahlungsstärke $1/e^2$ mit einem Durchmesser von 15 μm bis 30 μm auf der Schicht (d) zu erhalten.

Revendications

1. Appareil pour exposer selon une image une couche sensible aux infrarouges, l'appareil comprenant :

- un ensemble de support comprenant :
 - une surface cylindrique rotative ayant un axe longitudinal, la couche étant à même d'être montée extérieurement sur la surface cylindrique, et
 - un ensemble moteur pour faire tourner la surface cylindrique,
- un ensemble à laser pour produire un faisceau modulé en image, 10
- un ensemble optique comprenant :
 - une lentille pour focaliser le faisceau dirigé sur la couche sur la surface cylindrique, et
 - un ensemble moteur de focalisation pour déplacer la lentille par rapport à la couche sur la surface cylindrique afin de focaliser le faisceau modulé de manière que le faisceau modulé focalisé soit à même de graver la couche;
- un ensemble à chariot délivrant le faisceau modulé comprenant : 20
 - un chariot pour supporter l'ensemble optique,
 - une piste linéaire le long de laquelle le chariot est à même de se déplacer, la piste étant parallèle à l'axe longitudinal, et
 - un ensemble moteur de translation pour transporter le chariot le long de la piste afin de balayer le faisceau modulé en image le long de la couche sur la surface cylindrique à une vitesse d'avancement du chariot d'environ une largeur d'exposition du faisceau modulé sur la couche de la surface cylindrique;
- un ensemble informatique pour (i) recevoir, générer et/ou stocker des données d'image représentant une image à exposer sur la couche, et (ii) sélectionner des paramètres d'exposition dans un ensemble constitué de la vitesse de la surface cylindrique, de la vitesse d'avancement du chariot, des coordonnées d'emplacement de l'image sur la couche, de la position de focalisation et du niveau de modulation d'amplitude; et
- un ensemble de commande électronique pour recevoir les données d'image et les paramètres d'exposition de l'ensemble informatique et traiter les données d'image et les paramètres d'exposition pour commander l'ensemble de support, l'ensemble à laser, l'ensemble optique et l'ensemble à chariot pour la délivrance du faisceau modulé pour exposer l'image en mode spiralé

5

10

15

20

25

30

35

40

45

50

55

dans la couche;

caractérisé en ce que ledit appareil est à même de délivrer un faisceau modulé focalisé comprenant un rayonnement infrarouge ayant un pic de densité de puissance de 0,1 à 17 MW/cm² et qui est à même d'offrir une densité d'énergie de 0,5 à 5 J/cm² sur ladite couche suffisante pour assurer l'ablation de la couche sensible aux infrarouges.

2. Appareil selon la revendication 1, dans lequel : l'ensemble à laser comprend :

- un laser pour émettre un faisceau de rayonnement infrarouge de sortie ayant une valeur de qualité de faisceau M² de 4 à 8 et une puissance maximale de 50 à 70 W;
- une source d'alimentation laser pour exciter le laser; et
- un ensemble modulateur acousto-optique pour moduler le faisceau de sortie laser par des données d'image et pour produire un faisceau modulé en image de premier ordre ayant une puissance maximale de 22 à 32 W; et

l'ensemble de commande électronique est à même de commander l'ensemble modulateur acousto-optique.

3. Appareil selon la revendication 2, dans lequel l'ensemble modulateur acousto-optique comprend :

- un modulateur acousto-optique pour diffracter une partie de premier ordre du faisceau de sortie laser et pour laisser passer une partie d'ordre zéro du faisceau de sortie laser; et
- un piège à faisceau pour bloquer la partie de faisceau du premier ordre ou la partie de faisceau d'ordre zéro.

4. Appareil selon la revendication 1, comprenant par ailleurs un système d'extraction de débris pour évacuer le matériau éliminé par ablation, le système de commande électronique étant par ailleurs à même de commander le système d'extraction de débris.

5. Procédé de préparation d'une plaque d'impression flexographique, comprenant les étapes consistant :

(1) à mettre en oeuvre un élément d'impression photosensible comprenant dans l'ordre énuméré :

- (a) une couche de support,
- (b) au moins une couche photopolymérisable comprenant un liant élastomère, au moins un monomère et au moins un initiateur ayant une sensibilité au rayonnement

- actinique non infrarouge, ladite couche photopolymérisable étant soluble, gonflable ou dispersable dans une solution révélatrice;
- (c) en option au moins une couche barrière qui est sensiblement transparente au rayonnement actinique non infrarouge; et
- (d) au moins une couche de matériau sensible aux rayons infrarouges qui est sensiblement opaque au rayonnement actinique non infrarouge;
- (2) à procéder à l'ablation selon une image de la couche (d) par un faisceau de rayonnement laser infrarouge ayant un pic de densité de puissance de 0,1 à 17 MW/cm² et qui est à même d'offrir une densité d'énergie de 0,5 à 5 J/cm² à partir d'un appareil d'ablation à laser pour former un masque, l'appareil comprenant un ensemble de support, un ensemble à laser, un ensemble optique, un ensemble à chariot délivrant le faisceau modulé, un ensemble informatique et un ensemble de commande électronique;
- (3) à exposer globalement l'élément photosensible à un rayonnement actinique non infrarouge à travers le masque; et
- (4) à traiter le produit de l'étape (3) par au moins une solution révélatrice pour éliminer (i) la couche sensible aux infrarouges qui n'a pas été éliminée au cours de l'étape (2), (ii) au moins des zones de la couche barrière, si elle est présente, qui n'ont pas été exposées au rayonnement actinique non infrarouge, et (iii) des zones de la couche photopolymérisable (b) qui n'ont pas été exposées au rayonnement actinique non infrarouge.
6. Procédé selon la revendication 5, comprenant par ailleurs les étapes consistant :
- à éliminer une feuille de recouvrement de l'élément; et,
 - après l'étape d'élimination et avant l'étape d'ablation, à monter l'élément sur une surface cylindrique rotative de l'ensemble de support.
7. Procédé selon la revendication 5, comprenant par ailleurs l'étape consistant :
- à utiliser le faisceau de rayonnement laser infrarouge ayant une valeur de qualité de faisceau M² de 4 à 8 et une puissance maximale de 50 - 70 W.
8. Procédé selon la revendication 5, dans lequel l'étape d'ablation est réalisée :
- en faisant tourner la surface cylindrique à une vitesse de 500 à 2500 tours par minute tout en déplaçant simultanément l'ensemble optique de manière générale parallèlement à un axe longitudinal de la surface cylindrique pour éliminer par ablation une image en mode spiralé dans la couche (d) à une vitesse d'avancement d'environ une largeur d'ablation sur la couche par tour de la surface cylindrique.
9. Procédé selon la revendication 5, comprenant par ailleurs l'étape de focalisation du faisceau de rayonnement laser infrarouge pour qu'il ait un diamètre d'irradiation de 1/e² de 15 µm à 30 µm sur la couche (d).

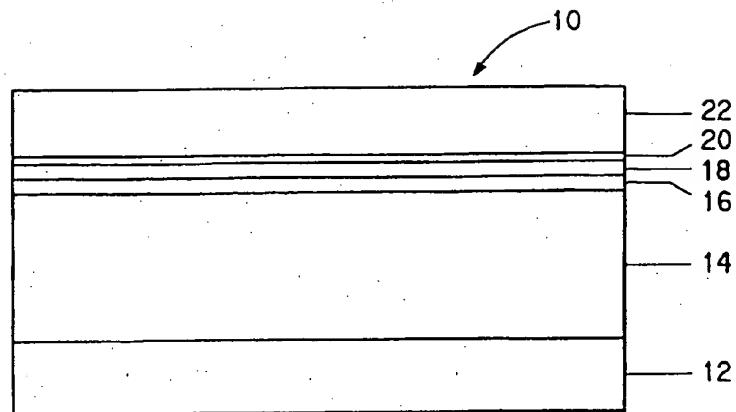


FIG. 1

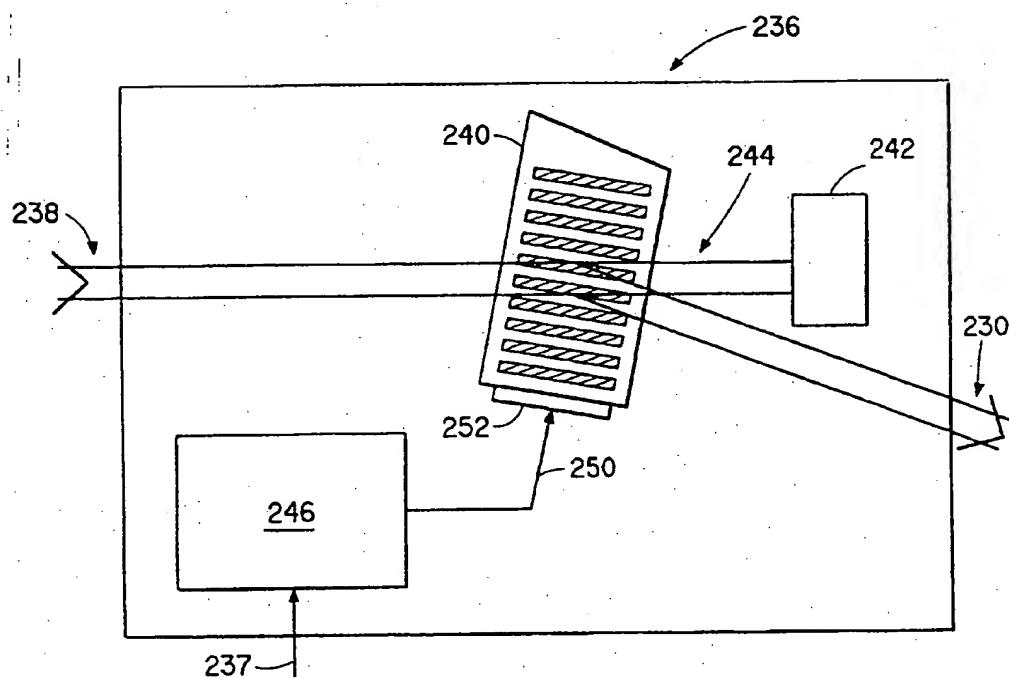


FIG. 3

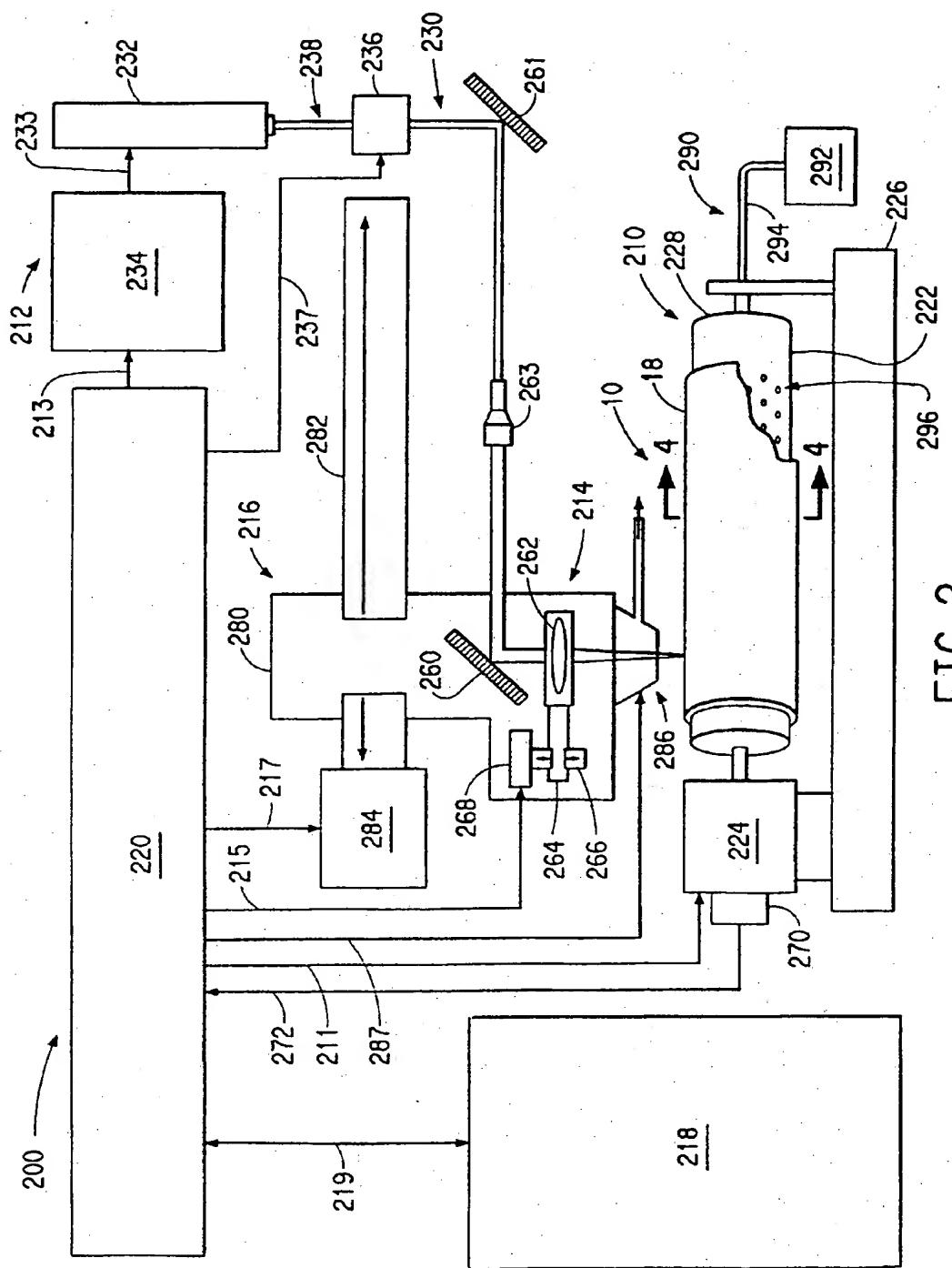


FIG. 2

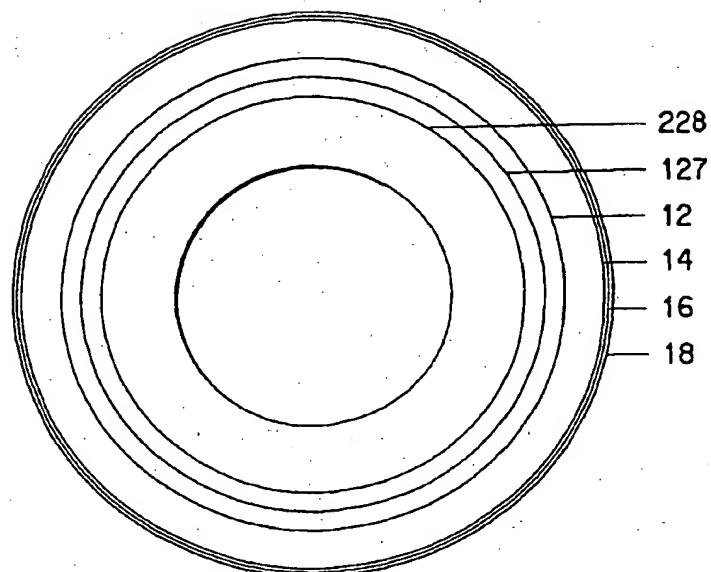


FIG. 4

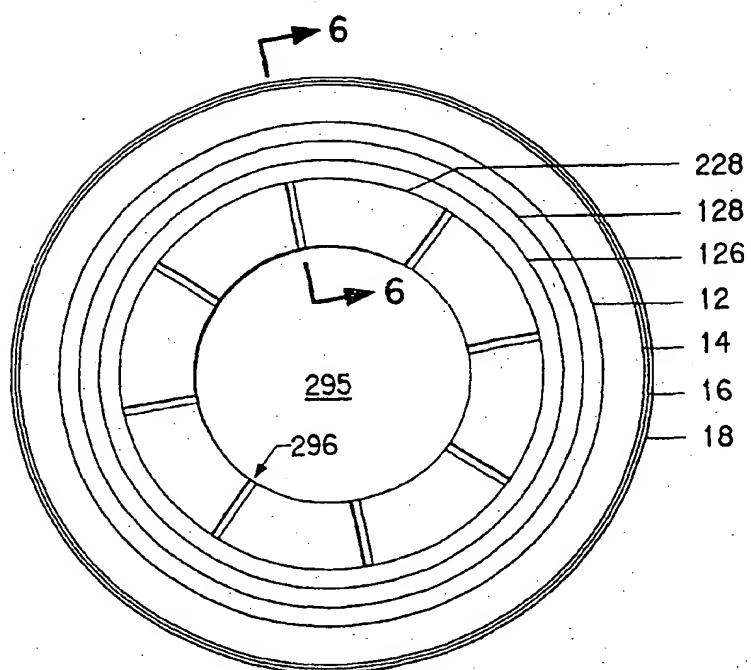


FIG. 5

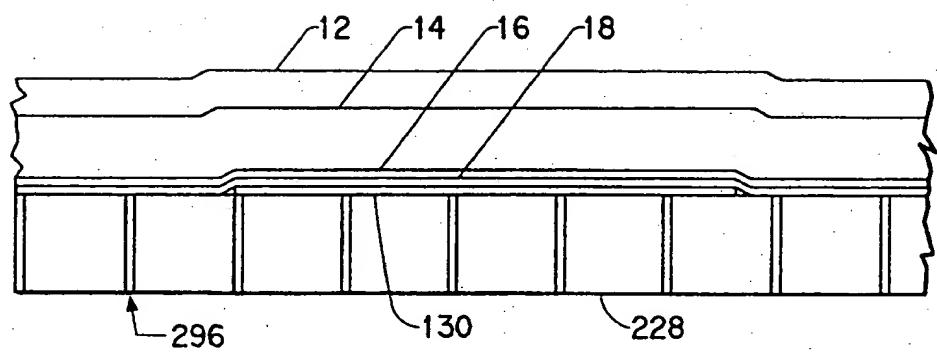


FIG.6